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Flexible, transparent single-walled carbon nanotube transistors with graphene electrodes

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Abstract
This paper reports a mechanically flexible, transparent thin film transistor that uses graphene as a conducting electrode and single-walled carbon nanotubes (SWNTs) as a semiconducting channel. These SWNTs and graphene films were printed on flexible plastic substrates using a printing method. The resulting devices exhibited a mobility of $\sim 2 \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, On/Off ratio of $\sim 10^2$, transmittance of $\sim 81\%$, and excellent mechanical bendability.

(Some figures in this article are in colour only in the electronic version)

1. Introduction

Flexible and transparent thin film transistors (TTFTs) have great potential in future display applications requiring both flexibility and transmittance, such as head-up and see-through displays embedded on the windshield of a car [1–3]. The traditional group of materials used to build TTFTs is the conducting (or semiconducting) oxides, including SnO₂, In₂O₃, ZnO, and CdO [4, 5]. These oxide materials provide good carrier mobility but generally lack mechanical flexibility. On the other hand, organic materials that can utilize low temperature processing are useful for flexible TTFTs, but their modest carrier mobility and environmental durability limit their range of application [6–8]. One of the promising alternatives is carbon based materials, such as single-walled carbon nanotubes (SWNTs) and graphene [1, 9–12]. These materials exhibit excellent mechanical and electrical properties owing to their unusual molecular structure [13–16]. As a representative example, transparent and flexible TTFTs that use highly conductive carbon nanotube films as the electrodes of transistors were demonstrated with the transfer printing technique [9, 10]. This paper reports transparent, flexible TTFTs with excellent performance, fabricated at room temperature using SWNT semiconducting thin films and graphene electrodes grown by chemical vapor deposition.

2. Experimental procedure

Figure 1 shows the device fabrication procedures, materials, and device structure as well as scanning electron microscopy (SEM) and optical microscope images. First, a purified SWNT solution (Nanointegris, IsoNanotubes-S™, semiconductor purity of 95%) was dropped onto a SiO₂ (thickness: 100 nm)/Si substrate and then placed in water for 30 min to remove the disperser and stabilize the adhesion between the SWNTs and the substrate. Next, a PET substrate coated with a graphene gate (G) electrode, and two intermediate films including graphene for the source (S)/drain (D) electrodes and SWNTs for the channels were prepared. For the S/D/G electrodes, two types of graphene film synthesized on a Ni(300 nm)/SiO₂(300 nm)/Si wafer and Cu foil (25 μm) catalyst layer by chemical vapor deposition at 1000°C were used as the S/D electrodes and G electrode, respectively [17–19]. The average number of graphene layers grown on the Ni catalyst and Cu foil ranged from three to five and from mono- to bilayer, respectively. The graphene films grown on Cu foil for the G electrode were transferred to PET...
Figure 1. (a) Schematic diagram of the fabrication procedures for flexible and transparent thin film transistors that use SWNT networks for the semiconducting layers and graphene for the S/D/G electrodes. The process involves transfer printing of SWNTs and graphene to form the semiconducting and conducting layers of the devices. (b) Schematic structure of the flexible TTFTs on the plastic substrate. (c) SEM image of the interface between a source/drain graphene electrode (left) and SWNT network channel layer (right). Inset: optical microscope image of a typical device. Black box indicates the magnified region by SEM.

To transfer the SWNTs film from the wafer to the target plastic substrate, an Au thin film (thickness: 20 nm) and a 10 wt% poly (vinyl alcohol) (PVA) solution were formed on the SWNTs [21, 22]. The PVA/Au/SWNTs film attached to a PDMS stamp with patterned graphene S/D electrodes can be peeled off easily. After dissolving PVA in hot water (80 °C) and etching Au, a SWNTs film on a graphene/PDMS stamp was obtained. These SWNTs/graphene layers were transfer printed on SiO2 (thickness: 100 nm)/graphene/PET substrates coated with a thin photocurable epoxy adhesive layer (SU8-2, Microchem Corp., thickness: 500 nm). Here, epoxy and SiO2 served as a double layer gate dielectric. After completing all the printing processes, the devices were isolated by conventional photolithography and reactive ion etching with O2 plasma.

Figure 1(b) shows a schematic diagram of the device structure of the SWNTs semiconducting channels and graphene electrodes. Figure 1(c) shows a SEM image of the boundary between the S/D graphene electrode (left) and SWNTs network channel layer (right) on the PET substrates. This image indicates that the SWNTs are dispersed completely with a density of ∼3 tubes µm−2 and the S/D graphene electrodes cover the SWNTs perfectly. The inset shows an optical microscopy image of a typical device. The channel length of this device was 50 µm with a corresponding width of 200 µm. The black box indicates the region of the device magnified by SEM.

3. Results and discussion

Figure 2(a) shows the transmission spectra in the visible range of all the carbon based thin film transistors, in which SWNT networks and graphene films serve as the channels and electrodes, respectively. The average transmittance through the channel region (SWNT/epoxy/SiO2/graphene) and source/drain region (graphene/SWNT/epoxy/SiO2/graphene) at 550 nm, exclusive of the bare PET substrate effect, were 91.3% and 81.4%, respectively. The transmittance of the source/drain region decreased by 9.9% compared to the channel. This corresponds to the opacity of visible light through four layers of graphene because a monolayer film leads to an approximate 2.3% decrease in transmittance [23]. In addition, all the carbon based devices showed less variation
Figure 2. (a) Optical transmittance as a function of wavelength for the PET substrate (black line), through the channel region (red line) and through the source/drain electrode (blue line) of the device including PET substrates. (b) Optical images of a completed array of the TTFTs on the PET substrate.

Figure 3. (a) Current–voltage characteristics of a TTFT with a 200 µm channel width and a 25 µm channel length (gate voltage, $V_{GS}$: −40 to 40 V from top to bottom; 10 V steps). (b) Transfer characteristics of TTFTs with different channel lengths on the PET substrate. The channel widths were 200 µm and the drain/source voltage ($V_{DS}$) was −0.1 V in all cases. (c) Effective device mobility and on/off ratios as a function of the channel length. (d) ON channel resistance as a function of the channel length at different gate voltages (gate voltage, $V_{GS}$: −15 to −30 V from top to bottom; 5 V steps).

in transmittance than ITO and a comparable degree of transparency to oxide material based devices [24]. Figure 2(b) shows an image of the device substrate to demonstrate the optical transmittance and mechanical bendability of these devices.

Figure 3(a) shows the current–voltage characteristics of a representative device with a 200 µm channel width and 25 µm channel length (gate voltage, $V_{GS}$: −40 to 40 V from top to bottom; 10 V steps). The unipolar p-type devices showed an effective mobility of $\sim 2 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$, on/off ratio of $\sim 10^2$ and threshold voltage of $\sim 7$ V. Figure 3(b) presents the transfer characteristics of the devices with different channel lengths ($L_C$) between 25 and 250 µm on a PET substrate. The channel widths were 200 µm and the drain/source voltage ($V_{DS}$) was −0.1 V in all cases. The ~90% devices exhibited stable operation without failure. Device failure was caused mainly by gate leakage. Figure 3(c) summarizes the effective device mobility and on/off ratios of the devices as a function
of the channel length. The on/off ratios ranged from $10^2$ to $10^3$ and the effective mobility ranged from 0.5 to 2 cm$^2$ V$^{-1}$ s$^{-1}$, indicating that these values are not dependent on the channel lengths [25–27]. This channel length invariance of the mobility indicates that the contact resistance has a negligible effect on the devices. More detailed analysis using standard transmission line models was performed to evaluate the contact effect on the devices. More detailed analysis using standard mobility indicates that the contact resistance has a negligible compared to the channel resistance within the range of channel lengths investigated. This small resistance suggests good electrical contacts between the SWNTs and graphene electrodes. Graphene possesses a molecular structure basically identical to that of SWNTs, and the strong interaction between electrodes. Graphene has a good electrical contacts between the SWNTs and graphene electrodes. This channel length invariance of the bending induced strain and bending radius.

4. Conclusion

Transparent, all carbon based thin film transistors consisting of SWNTs semiconductors and graphene electrodes were fabricated. These devices exhibited good electrical, optical and mechanical properties. In particular, the graphene electrodes showed excellent contact properties with the SWNT channel materials. Overall, the characteristics of all carbon based devices observed in this study are very promising for future flexible electronic applications.

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References


Figure 4. (a) Optical image during the bending test. (b) The change in the normalized effective device mobility $\mu/\mu_0$ for TTFTs as a function of the channel length.
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